OIPE JC14
MAR 28 2005
PATENT & TRADEMARK OFFICE

IPW

PATENT

Atty. Dkt. No. AMAT/2592.C9/DSM/LOW K/JW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Gaillard, et al. §

Serial No.: 10/789,209 §

Confirmation No.: 9101 §

Filed: February 27, 2004 §

For: Method of Decreasing the K Value in SIOC Layer Deposited by Chemical Vapor Deposition §

§

Group Art Unit: 2818

Examiner: David Nhu

MAIL STOP AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

CERTIFICATE OF MAILING
37 CFR 1.8

I hereby certify that this correspondence is being deposited on 3/24, 2005 with the United States Postal Service as First Class Mail in an envelope addressed to: Mail Stop Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

3/24/05
Date

Signature

RESPONSE TO OFFICE ACTION DATED JANUARY 7, 2005

In response to the Office Action dated January 7, 2005, having a shortened statutory period for response set to expire on April 7, 2005, please enter this response and reconsider the claims pending in the application for reasons discussed below. The Commissioner is hereby authorized to charge counsel's Deposit Account No. 20-0782/AMAT/2592.C9/KMT for any fees, including extension of time fees or excess claim fees, required to make this response timely and acceptable to the Office.

Amendments to the Specification begin on page 2 of this paper. The **Pending Claims** are shown beginning on page 4 of this paper. **Remarks** begin on page 8 of this paper.